

iTops i233 Plus ITO Sputter System

System Overview

The iTops i233 Plus ITO Sputtering System deposits a high crystalline, uniform ITO film with excellent electrical conductivity and high visible light transmission.

Substrate Size:	50 mm, 100 mm, 150 mm
Applications compounds:	ITO
Technology Markets:	LED

Processes

- ITO current spread layer

Production Advantages

- ITO film with excellent conductivity and high light transmittance
- Unique processing technique reduces damage to the substrate
- Excellent film thickness uniformity, WIW, WTW and RTR
- Simple structure, flexible operation, and easy maintenance
- LED industry proven productivity & reliability



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